

REF	760-2	6×3mL	EXP	2024-06-18	LOT	48800F6	更新日期：	2024-05
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		批号：48800F6			
项目\仪器\试剂\方法	单位	均值 \ CV		Lab \ 点数	
(Ag)银					
OTHER Dedicated \ ICP-MS	mg/L	0.011	10.5%	<5	<100
(Al)铝					
OTHER Dedicated \ ICP-MS	mg/L	0.056	10.2%	<5	<100
(As)砷					
OTHER Dedicated \ ICP-MS	mg/L	0.012	9.5%	<5	<100
(Au)金					
OTHER Dedicated \ ICP-MS	μg/L	0.05	9.9%	<5	<100
(B)硼					
OTHER Dedicated \ ICP-MS	mg/L	0.032	9.2%	<5	<100
(Ba)钡					
OTHER Dedicated \ ICP-MS	mg/L	0.165	9.6%	<5	<100
(Be)铍					
OTHER Dedicated \ ICP-MS	mg/L	0.001	9.5%	<5	<100
(Bi)铋					
OTHER Dedicated \ ICP-MS	μg/L	5.32	9.9%	<5	<100
(Br)溴					
OTHER Dedicated \ ICP-MS	mg/L	0.855	10.5%	<5	<100
(Ca)钙					
OTHER Dedicated \ ICP-MS	mmol/L	1.38	9.2%	<5	<100
(Cd)镉					
OTHER Dedicated \ ICP-MS	μmol/L	0.051	9.8%	<5	<100
OTHER Dedicated \ ICP-MS	μg/L	5.68	9.8%	<5	<100
(Co)钴					
OTHER Dedicated \ ICP-MS	μmol/L	0.009	9.4%	<5	<100
OTHER Dedicated \ ICP-MS	μg/L	0.53	9.4%	<5	<100
(Cr)铬					
OTHER Dedicated \ ICP-MS	μg/L	9.95	10%	<5	<100
(Cs)铯					
OTHER Dedicated \ ICP-MS	mg/L	0.002	10.2%	<5	<100
(Cu)铜					
OTHER Dedicated \ ICP-MS	μmol/L	15.3	9.9%	<5	<100
(Fe)铁					
OTHER Dedicated \ ICP-MS	μmol/L	6086	9.4%	<5	<100
(Hg)汞					
OTHER Dedicated \ ICP-MS	μmol/L	0.112	9.3%	<5	<100
(I)碘					
OTHER Dedicated \ ICP-MS	μg/L	68.5	10.1%	<5	<100
(K)钾					
OTHER Dedicated \ ICP-MS	mmol/L	29.5	9.5%	<5	<100
(Li)锂					
OTHER Dedicated \ ICP-MS	mmol/L	0.002	8.8%	<5	<100
(Mg)镁					
OTHER Dedicated \ ICP-MS	mmol/L	1.71	9.8%	<5	<100
(Mn)锰					
OTHER Dedicated \ ICP-MS	μg/L	23.6	10.1%	<5	<100

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		批号：48800F6			
项目\仪器\试剂\方法	单位	均值 \ CV		Lab \ 点数	
(Mo)钼					
OTHER Dedicated \ ICP-MS	μg/L	5.52	9%	<5	<100
(Na)钠					
OTHER Dedicated \ ICP-MS	mmol/L	56.6	10.6%	<5	<100
(Ni)镍					
OTHER Dedicated \ ICP-MS	μg/L	9.53	9.4%	<5	<100
(P)磷					
OTHER Dedicated \ ICP-MS	mmol/L	5.98	9.7%	<5	<100
(Pb)铅					
OTHER Dedicated \ ICP-MS	μmol/L	1.62	9.7%	<5	<100
(Rb)铷					
OTHER Dedicated \ ICP-MS	mg/L	1.7	8.8%	<5	<100
(S)硫					
OTHER Dedicated \ ICP-MS	mg/L	1350	7.4%	<5	<100
(Sb)锑					
OTHER Dedicated \ ICP-MS	mg/L	0.024	10%	<5	<100
(Se)硒					
OTHER Dedicated \ ICP-MS	μmol/L	0.18	9.8%	<5	<100
(Si)硅					
OTHER Dedicated \ ICP-MS	mg/L	0.605	9.9%	<5	<100
(Sn)锡					
OTHER Dedicated \ ICP-MS	μg/L	3.95	10.1%	<5	<100
(Sr)锶					
OTHER Dedicated \ ICP-MS	mg/L	0.074	10%	<5	<100
(Ti)铈					
OTHER Dedicated \ ICP-MS	μg/L	3.35	8.9%	<5	<100
(V)钒					
OTHER Dedicated \ ICP-MS	μg/L	2.65	11.2%	<5	<100
(Zn)锌					
OTHER Dedicated \ ICP-MS	μmol/L	99.4	9.4%	<5	<100

注：此报告所提供的数据均基于检测相同批号质控品的若干实验室的数据汇总统计而来，仅供学习、参考之用。因所用技术、仪器和试剂的不同，或因制造商检测方法的改变，均可导致实验室实际测得的数据偏离此报告所提供的数据。根据良好实验室规范的要求，实验室须遵循相关技术规范确立自己的均值和可接受范围。